

## Mitigation of blistering effect on hydrogen transportation in ion-damaged tungsten

*Wednesday, 6 October 2021 11:20 (30 minutes)*

The effect of ion-induced damage on blistering and deuterium retention has been investigated in heavy-ion damaged tungsten (W) and a reference undamaged W sample with exposure to D plasma ( $40 \text{ eV}$ ,  $10^{22} \text{ m}^{-2} \text{ s}^{-1}$ ) at  $550 \text{ K}$ . Different damage depths are realized via copper (Cu) ion irradiation with energies of 1, 3, and 6 MeV on W samples with the same calculated peak damage level of 0.5 dpa. The Cu ion irradiation is shown to give rise to a reduction in blister density in W samples, and such a phenomenon becomes more pronounced as the damage depth increases. The D-rich region (with a D concentration larger than 0.5 at.%) in the near-surface extends inward and the total D retention increases with the increasing damage depth. A combined investigation using nuclear reaction analysis and thermal desorption spectroscopy reveals that D accumulates also at a depth beyond  $7.4 \mu\text{m}$  which is far beyond the damage depth, and D retention at a depth beyond  $7.4 \mu\text{m}$  rises with the damage depth. It suggests that the D diffusion flux into the bulk in the damaged case is higher than that in the undamaged case during the D plasma exposure. This phenomenon is attributed to the difference in the surface blister density, which alters the inward D diffusion flux by affecting the re-emission of D from the surface, and the D trapping at blisters in the blistering-relevant depth.

**Primary authors:** Mr WANG, Shiwei (Beihang University); CHENG, Long (Beihang University); Dr SCHWARZ-SELINGER, Thomas (Max-Planck-Institut für Plasmaphysik); Dr YUAN, Yue (Beihang University); Prof. LU, Guang-Hong (Beihang University)

**Presenter:** CHENG, Long (Beihang University)

**Session Classification:** Retention